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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/827,437	0/827,437 04/20/2004		Takeshi Akatsu	4717-13000	2732
28765	7590	10/16/2006		EXAMINER	
WINSTON 1700 K STR			KUNEMUND, ROBERT M		
WASHING	•			ART UNIT	PAPER NUMBER
,				1722 DATE MAILED: 10/16/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)					
Office Action Summer	10/827,437	AKATSU ET AL.					
Office Action Summary	Examiner	Art Unit					
	Robert M. Kunemund	1722					
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the o	correspondence address					
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING D. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period v. - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tir will apply and will expire SIX (6) MONTHS from to cause the application to become ABANDONE	N. nely filed the mailing date of this communication. (D (35 U.S.C. § 133).					
Status							
1) Responsive to communication(s) filed on 31 Ju	<u>ıly 2006</u> .						
2a)⊠ This action is FINAL . 2b)□ This	action is non-final.						
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11, 49	53 O.G.·213.					
Disposition of Claims							
4) Claim(s) 1-23 is/are pending in the application.							
4a) Of the above claim(s) is/are withdraw	4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>1-23</u> is/are rejected.	· ·						
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/o	r election requirement.						
Application Papers							
9) The specification is objected to by the Examine	r.						
10)☐ The drawing(s) filed on is/are: a)☐ acce	epted or b) objected to by the I	Examiner.					
Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	e 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correct	•						
11) The oath or declaration is objected to by the Ex	raminer. Note the attached Office	Action or form PTO-152.					
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:	priority under 35 U.S.C. § 119(a))-(d) or (f).					
1. ☐ Certified copies of the priority documents	s have been received.						
2. Certified copies of the priority documents have been received in Application No							
3. Copies of the certified copies of the prior							
application from the International Bureau	ı (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list	of the certified copies not receive	ed.					
•							
Attachment(s)							
1) Notice of References Cited (PTO-892)	4) Interview Summary						
2)	Paper No(s)/Mail Da 5) Notice of Informal P						
Paper No(s)/Mail Date	6) Other:						

DETAILED ACTION

Claim Rejections - 35 USC § 102

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1 to 5, 8, 9, 11, 14 and 15 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by Huang et al (Applied physics letters).

The Huang et al reference teaches a method of producing a layer on a substrate, note entire reference. On a first substrate, with a lattice mismatch, a relax layer is grown, note page 1267. The layer can be silicon-germanium and a thickness of less than 5 um. The substrate can be silicon, note page 1267. Then an ion implantation is done using hydrogen to create a damaged area. A second substrate is bonded to the grown layer. The second substrate is then separated from the first substrate taking the grown layer with it, note figure 1. The resultant structure can then have further growth on it.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein

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were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 6, 7, 10, 12, 13 and 16 to 23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Huang et al.

The Huang et al reference is relied on for the same reasons as stated, supra, and differs from the instant claims in materials deposited, and processing conditions. However, in the absence of unexpected results, it would have been obvious to one of ordinary skill in the art to determine through routine experimentation the optimum. operable materials to be deposited and processing conditions in the Huang et al reference in order to create a specific device, using different materials, and removing defects by annealing and the process conditions.

Response to Applicants' Arguments

Applicant's arguments filed July 31, 2006have been fully considered but they are not persuasive.

Applicants' argument concerning the Huang et al reference is noted. However, the reference does teach the claimed invention. The reference teaches a first strained relaxed layer, removing it and bonding it to another substrate. There is more growth on Application/Control Number: 10/827,437

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that layer. These steps are the same as instantly claimed. The reference teaches the process on page 1265.

Applicants' argument concerning the second growth has been considered and not deemed persuasive. The reference doe in fact teach further epitaxial growth on the transferred layer meeting the claimed limitations.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Robert M. Kunemund whose telephone number is 571-272-1464. The examiner can normally be reached on 8 hours.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Yogendra Gupta can be reached on 571-272-1312. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Robert M Kunemund Primary Examiner Art Unit 1722

RMK